

Physics of high-current diode

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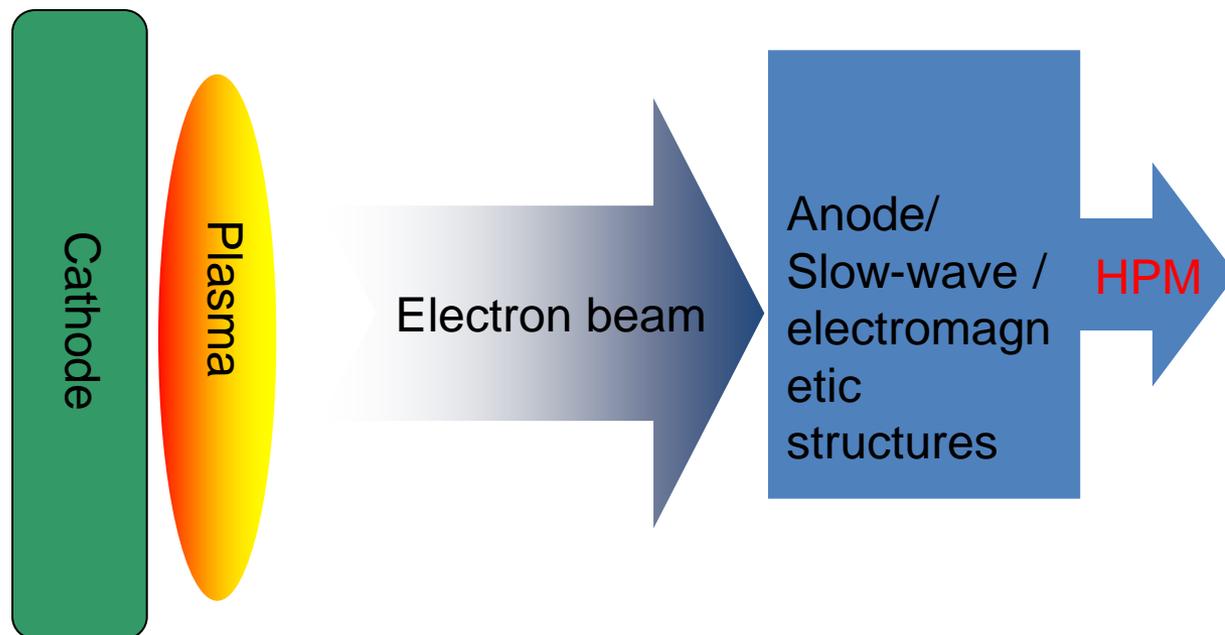


國防科學技術大學

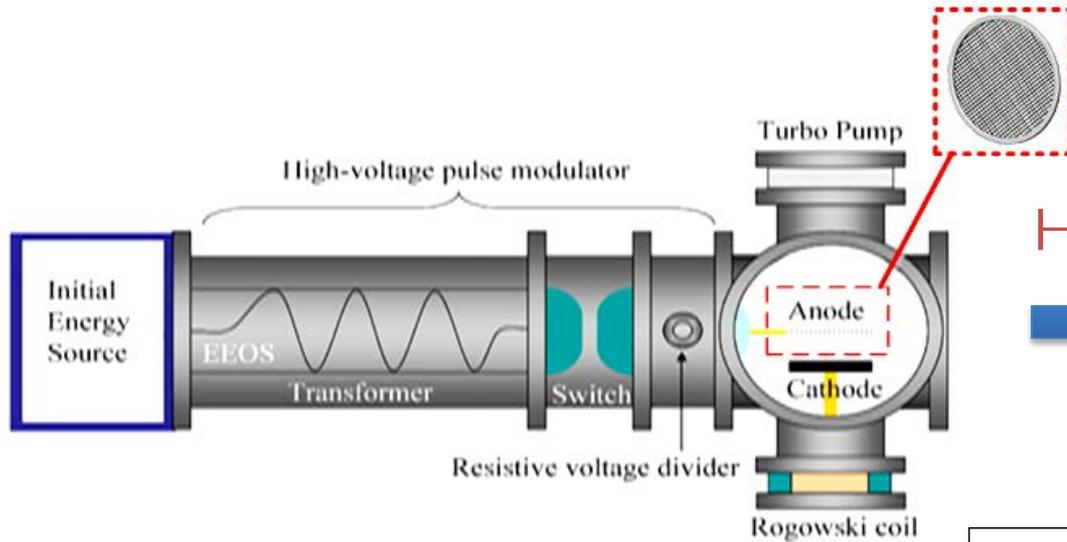
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Content

- 1 Electron emission mechanisms and fabrication of cathode
- 2 Plasma formation and diagnostics in high-current diode
- 3 Experimental investigation of anode physics
- 4 Applications in different high power microwave (HPM) sources
- 5 On-going research



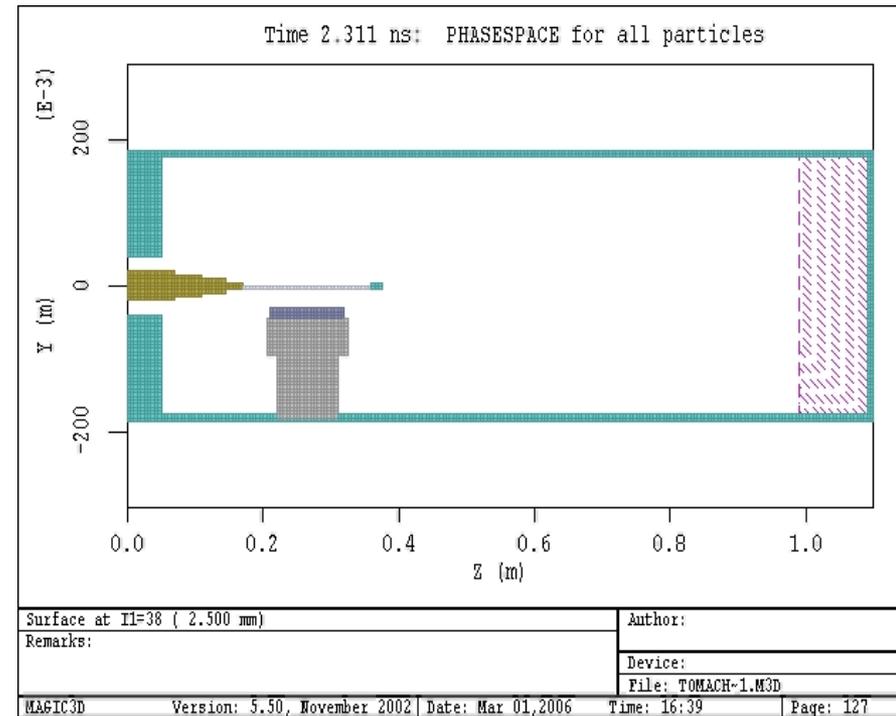
Schematic of high-current diode



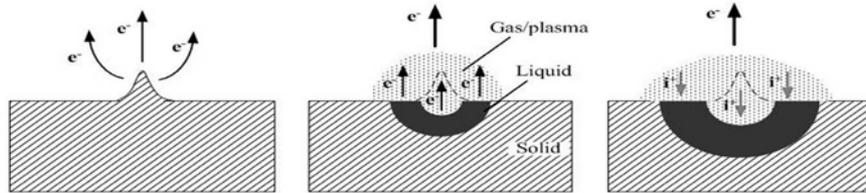
High-power microwave



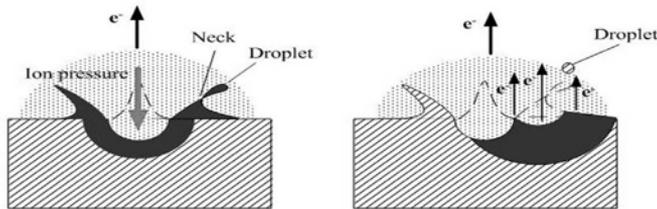
PIC simulation



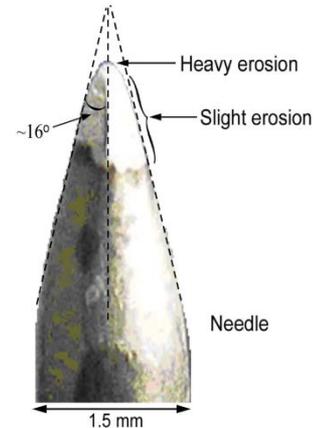
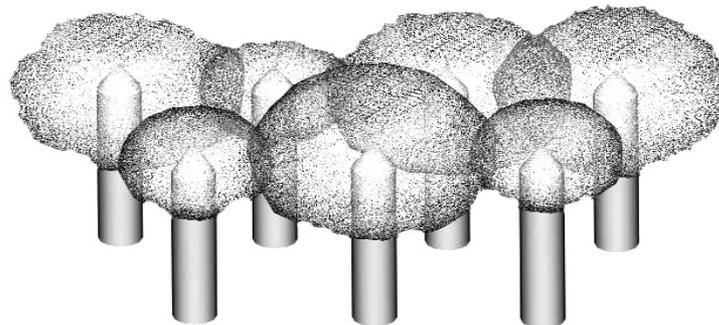
1. Cathode emission physics



$$E \sim \sigma \sim r^{-2}$$



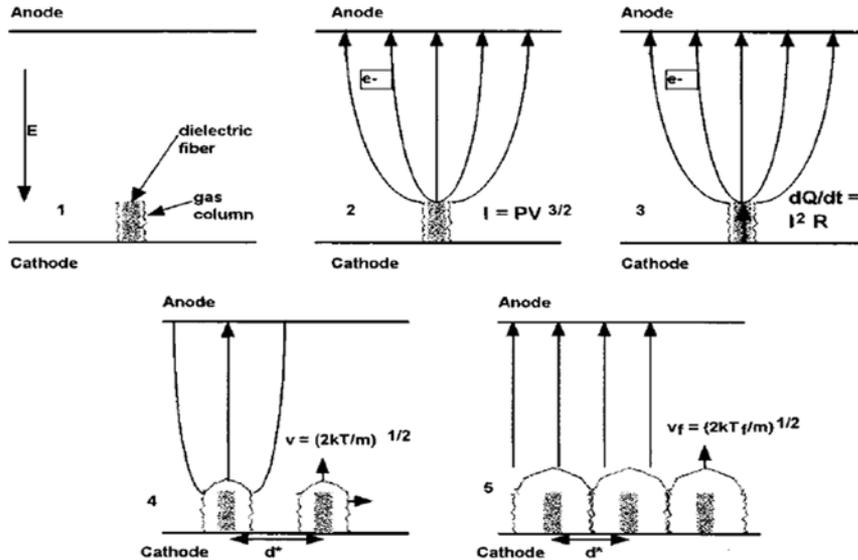
Explosive electron emission only



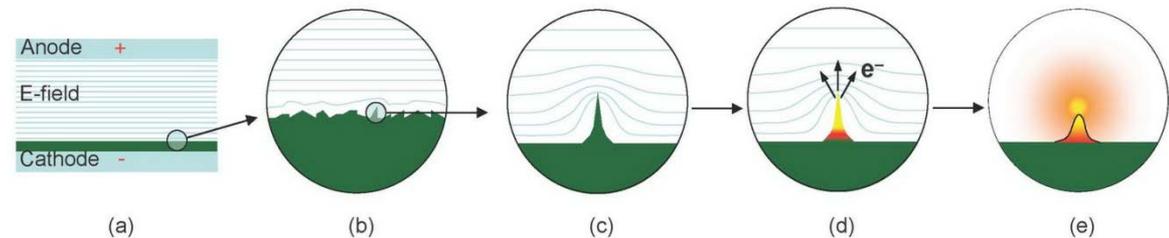
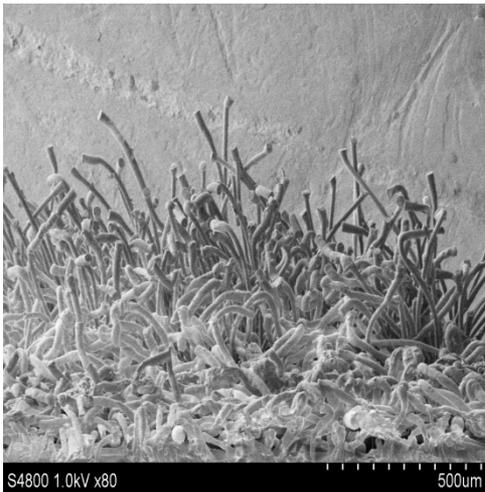
Metal cathode



- o Fast plasma expansion velocity
- o Time delay in plasma appearance
- o Non-uniformity in plasma distribution



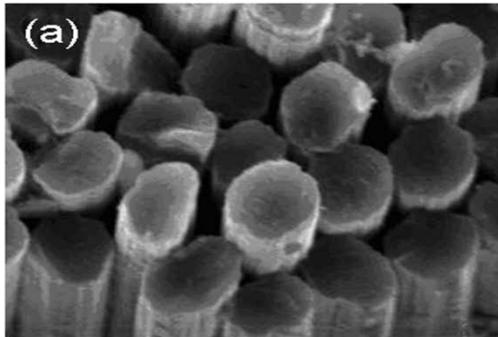
Surface flashover



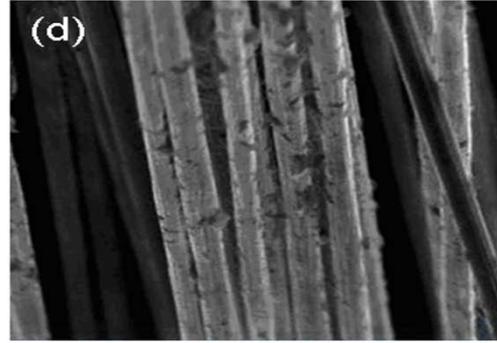
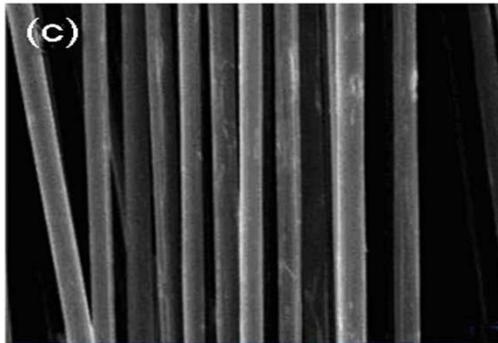
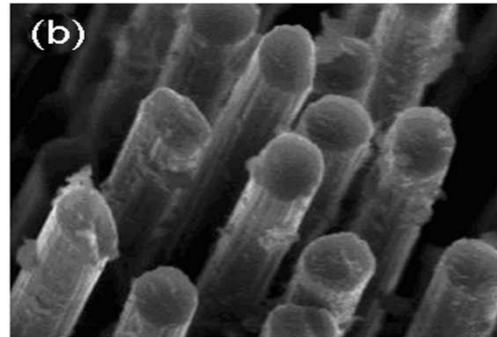
Polymer velvet cathode

- Low electric field threshold of electron emission (few kV/cm)
- Quasi-constant diode impedance behavior
- CsI coating superior diode operation

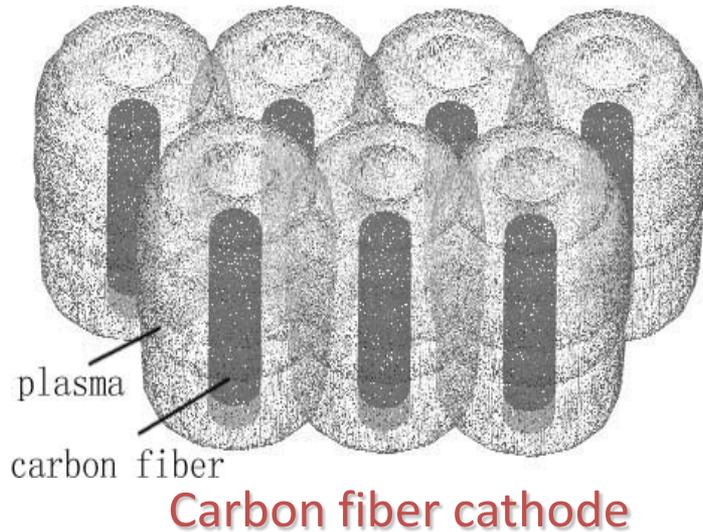
Before emission



After emission



Tracking of emission



1. Explosive electron emission
2. Surface flashover
3. Additional photo-electron emission with CsI coating

Lie Liu, et al., *High Power Laser and Particle beams*, Vol. **17**, pp. 1205-1209 (2005)

Hybrid emission mechanisms

Carbon Fiber Cathode

- 1. Explosive electron emission*
- 2. Surface flashover*
- 3. Additional photo-electron emission for CsI
(good UV emitter) coating*

Thus, we can conclude that an optimized cathode should have several electron emission mechanisms, and thus the uniformity of the whole electron emission surface of the cathode may be increased.

Property of carbon fiber

1. Light weight, high strength, high modulus

carbon fiber density: $1.6\sim 2.15\text{g/cm}^3$

tensile strength: $>2.2\text{GPa}$

modulus: $>230\text{GPa}$

2. Low coefficient of thermal expansion

Room temperature: $(-0.5\sim -1.6)\times 10^{-6}/\text{K}$,

at $200\sim 400^\circ\text{C}$: zero

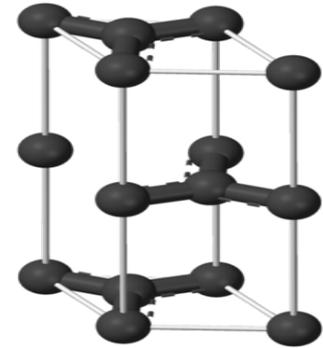
at $<1000^\circ\text{C}$: $1.5\times 10^{-6}/\text{K}$

3. Electric property between metal and non-metal

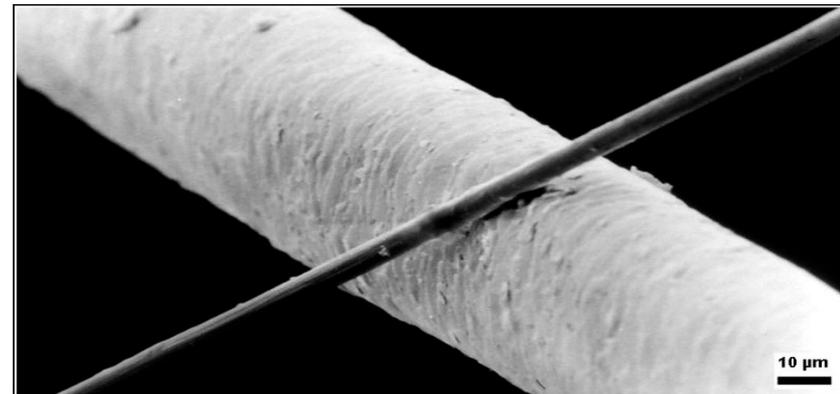
4. Boiling Point/Range: $>3600^\circ\text{C}$

Melting Point/Range: Not available

5. Excellent chemical resistance



Carbon unit cell



Thickness of carbon fiber and hair

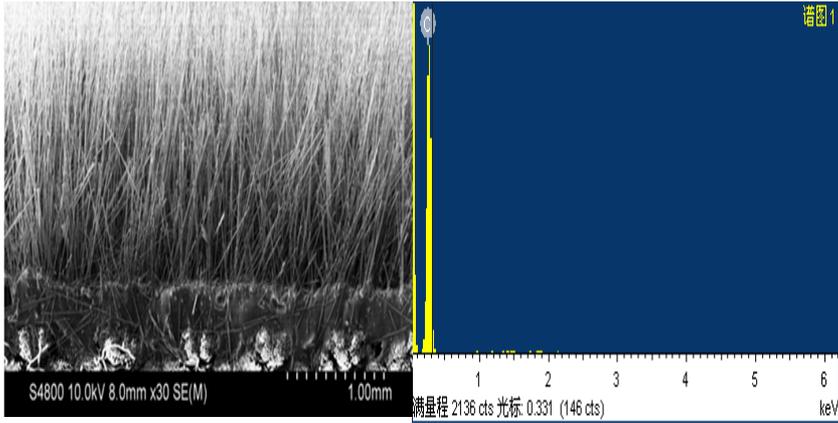
How to construct carbon fiber cathodes?



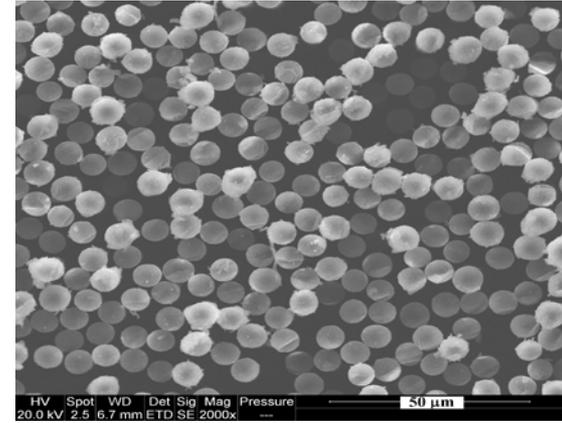
Robust (long life), easily shaped, and free-epoxy
(Invention Patent No. 200310102051.7)

The advantages carbon-fiber cathode for electron emission:

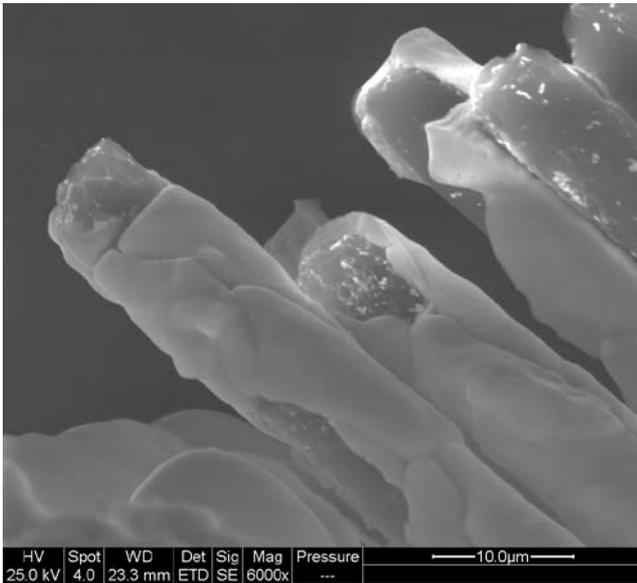
- o larger field amplification factor.
- o lower turn-on field and threshold field for emission.
- o higher intensity of electrical current.
- o better uniformity in emission
- o lower plasma expansion velocity .
- o stronger to stand against the bombardment (long life)



Scanning electron microscope (SEM) image of carbon fiber cathode (side)



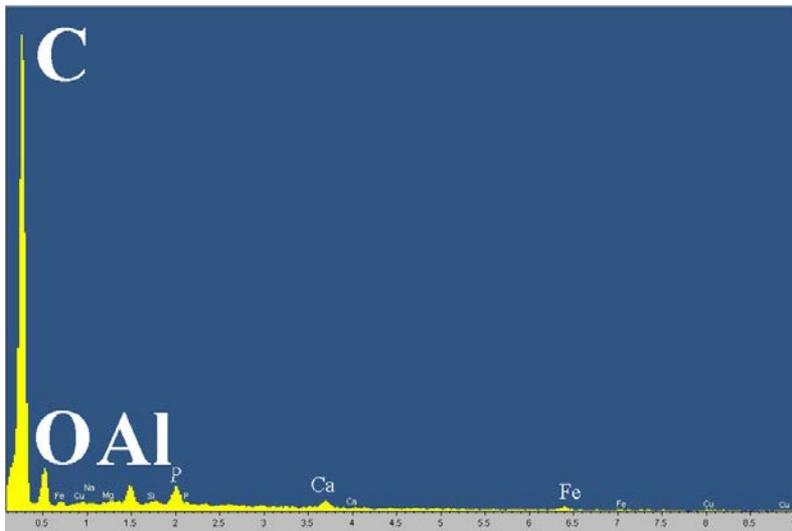
Scanning electron microscope (SEM) image of carbon fiber cathode (top)



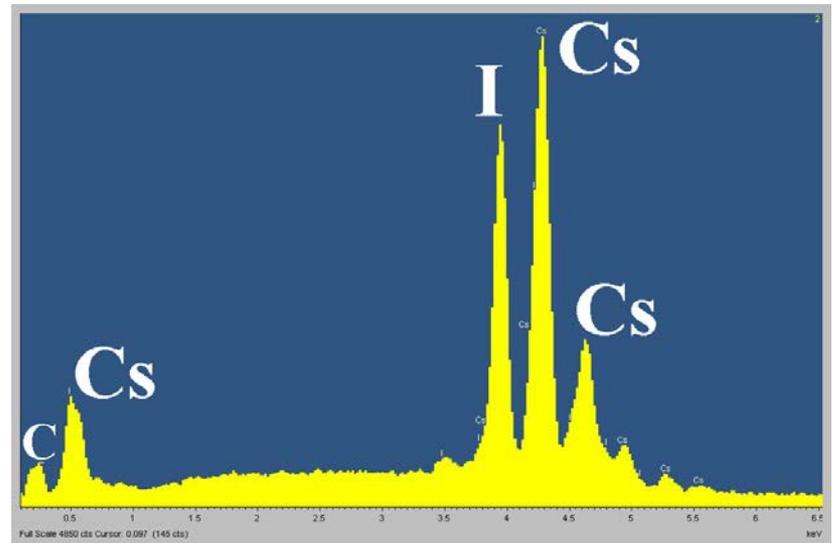
Scanning electron microscope (SEM) image of carbon fiber cathode (side) with CsI Coating

Cathode with CsI coating

Energy distribution spectrum (EDS) of the materials on the carbon fibers with and without CsI coating



Without CsI coating

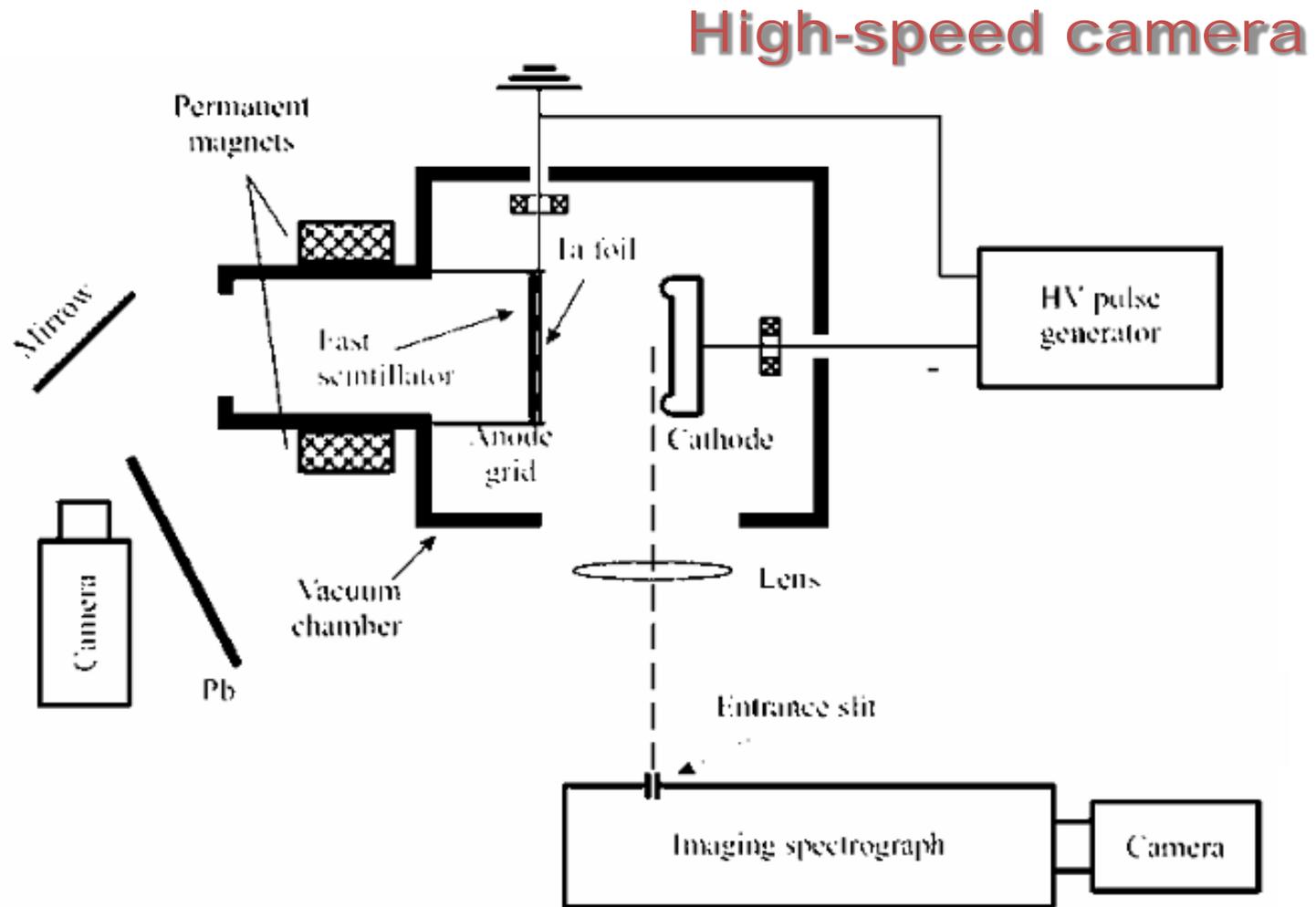


With CsI coating

Properties of ideal pulsed electron source

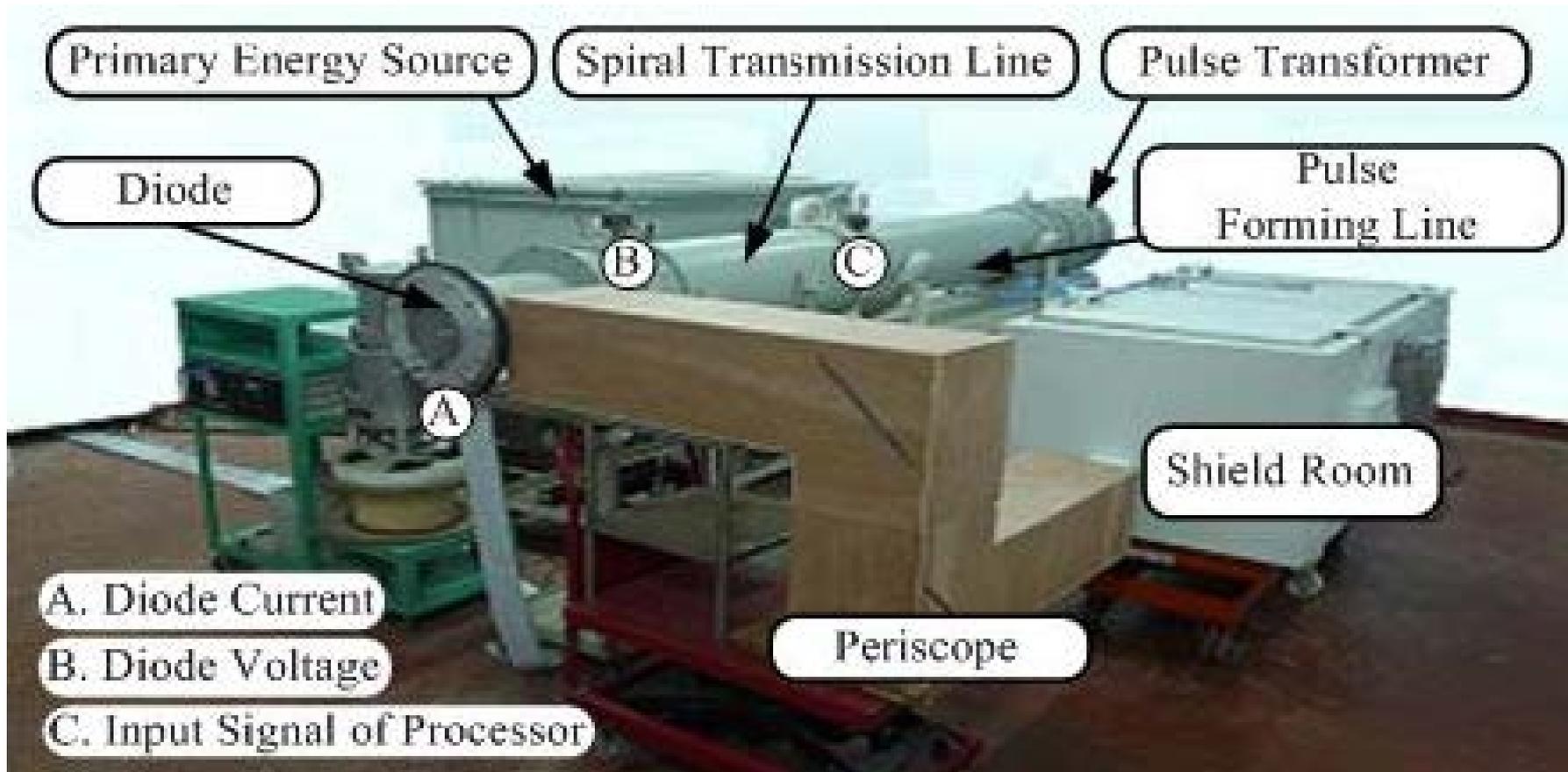
- Low electric field threshold for electron emission (<50 kV/cm)
- Nanosecond timescale turn-on
- Long life-time (>10⁷ pulses)
- High current densities (kA/cm²)
- Quasi-constant perveance of the diode, a slow plasma expansion rate
- Uniformity and arbitrary cross-section
- Vacuum (10⁻⁴ – 10⁻⁵ Torr) compatibility, low outgassing rate
- Low power consumption

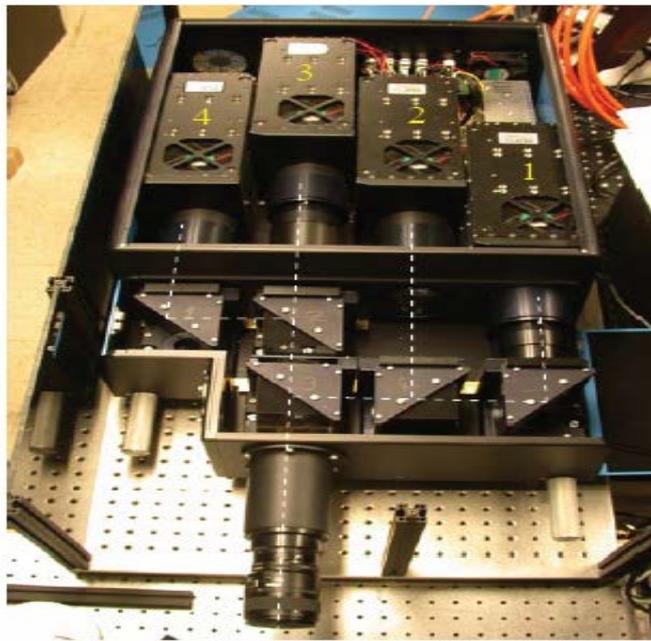
2. Diagnostics in diode



Testing system of optical assistant diagnostics

Testing system of diagnostics





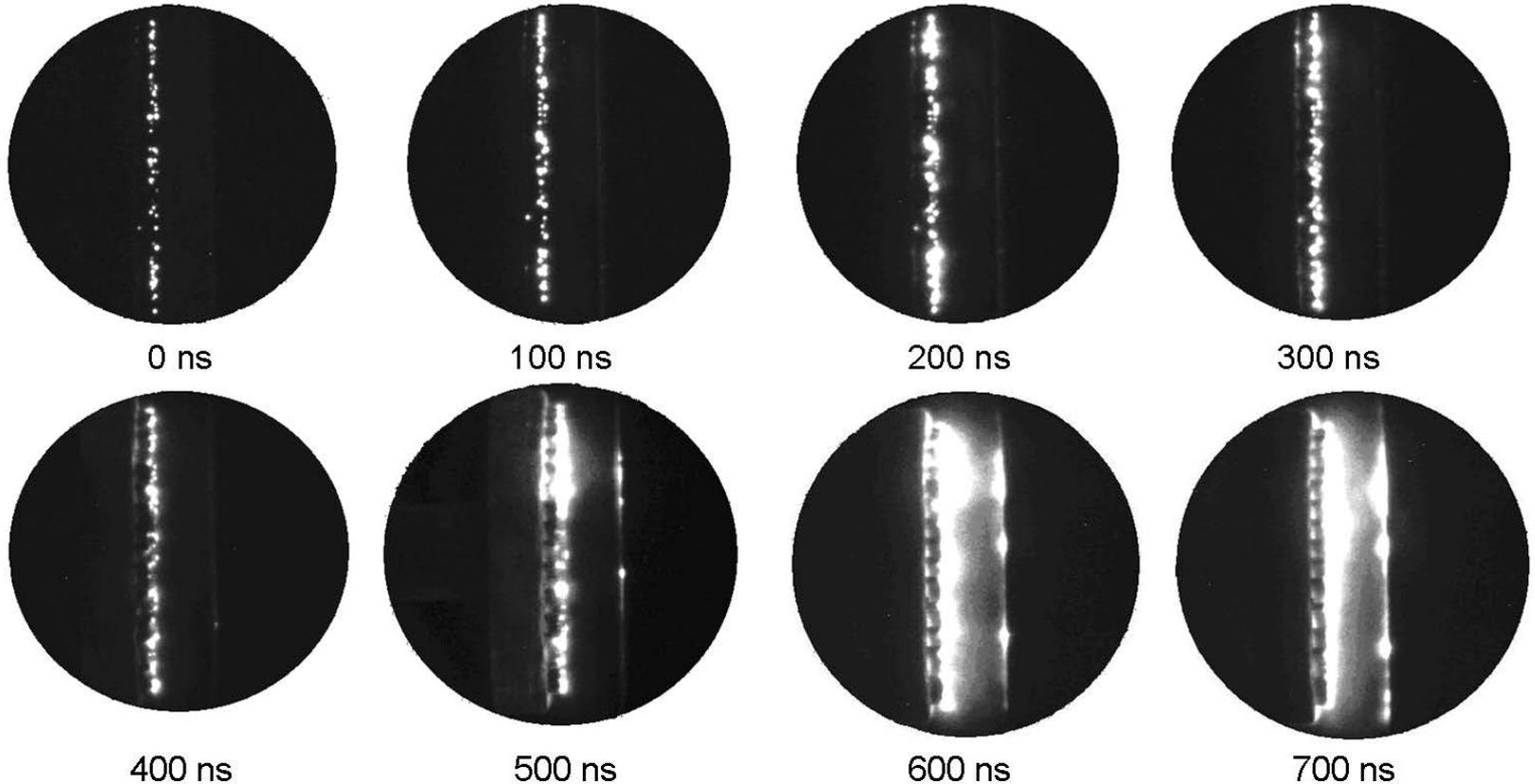
HSFC-PRO
(High Speed Framing Camera)



A Mach-Zehnder interferometer was designed and used to measure the plasma density in the diode.

Expansion of Plasma in Diode

Gap distance 1.9cm



oCathode turn-on at $t=0$ ns

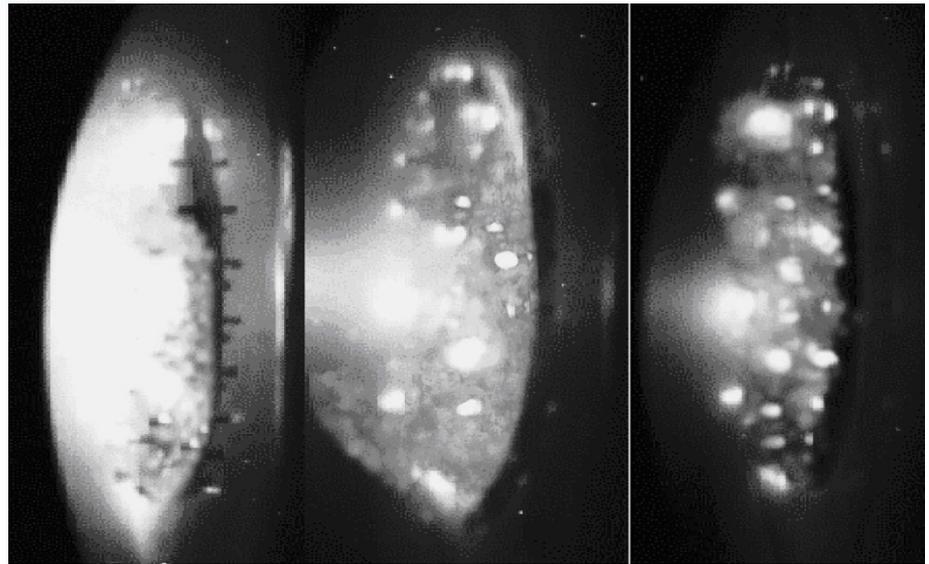
oQuasi-equilibrium process during $t=0-400$ ns

oInertial characteristic or anode plasma or both after $t=400$ ns

High current densities (kA/cm²)



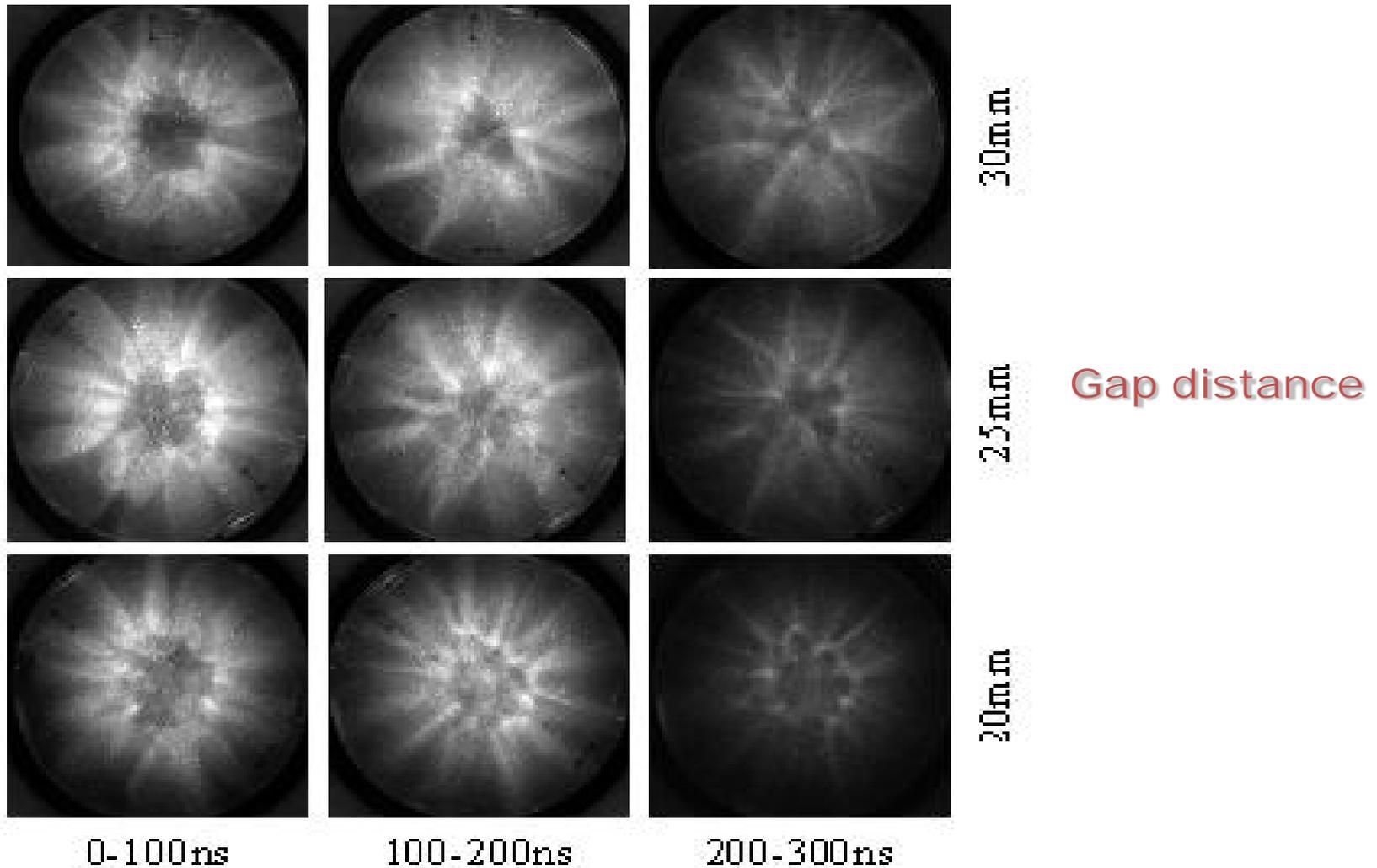
Emitting spots



Time-and-space resolved observations

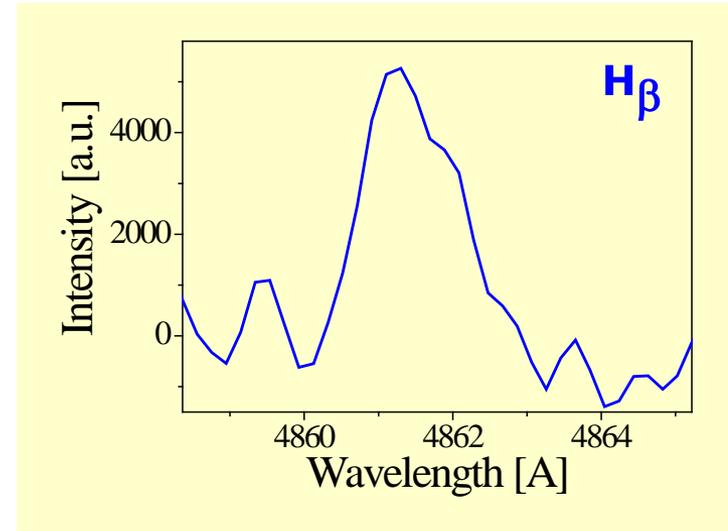
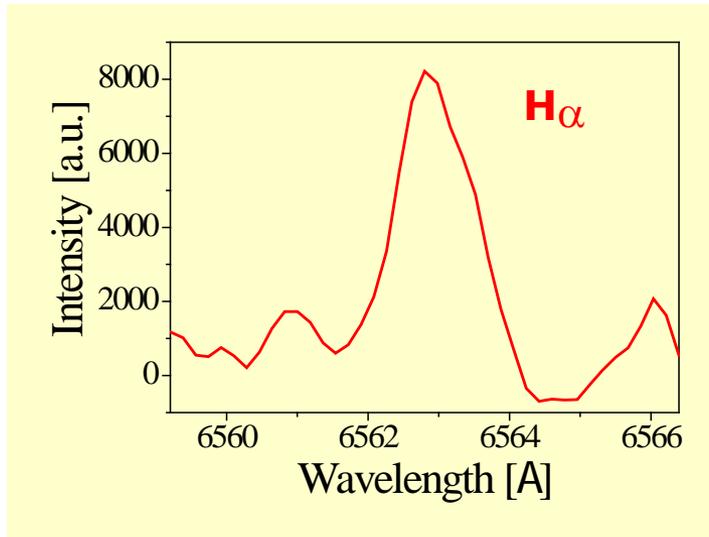
X-ray imaging in time and space

(Scintillator film (EJ-260) attach to anode)



Time

Spectroscopic diagnostics



Stark broadening



Plasma density: $(4.5 \pm 1.3) \times 10^{14} \text{cm}^{-3}$

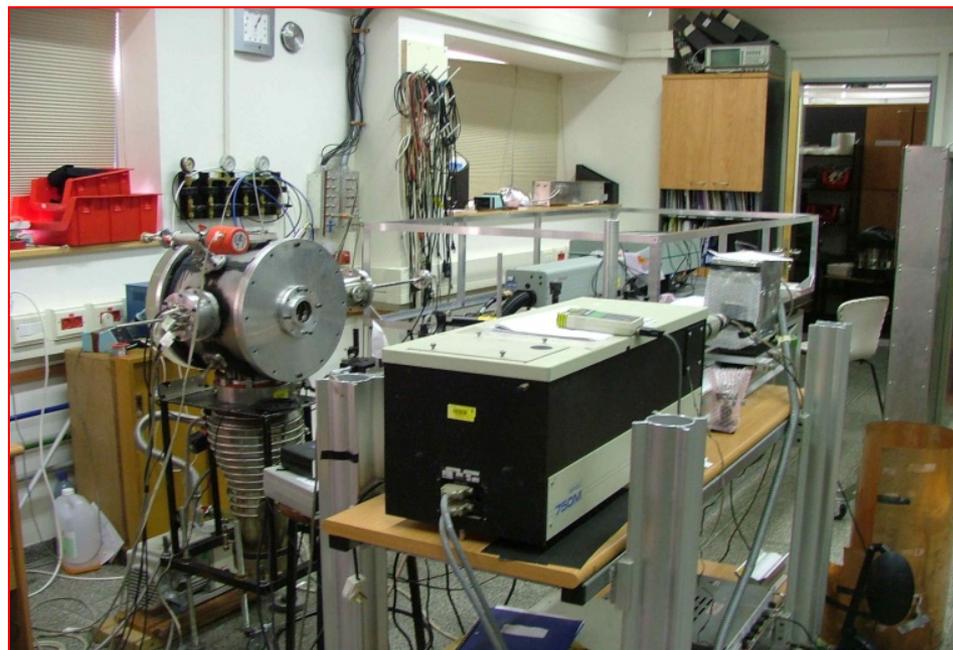
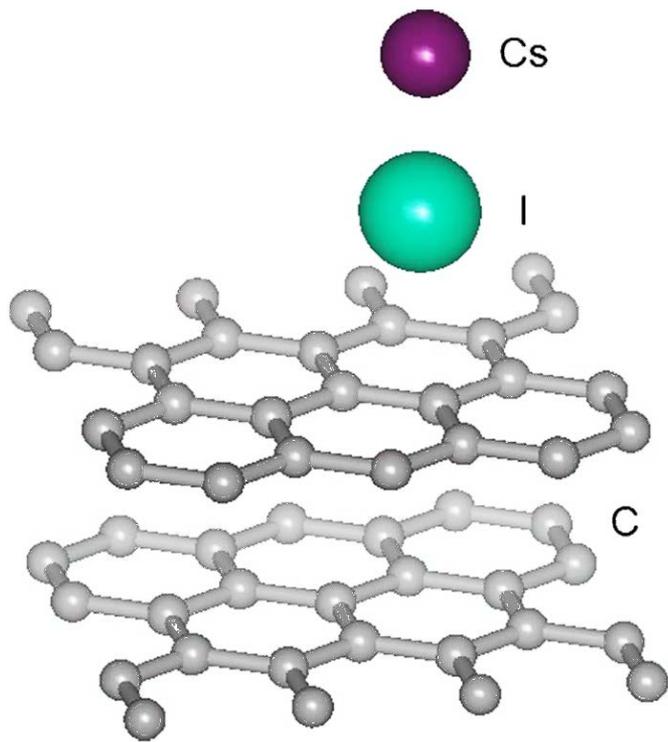
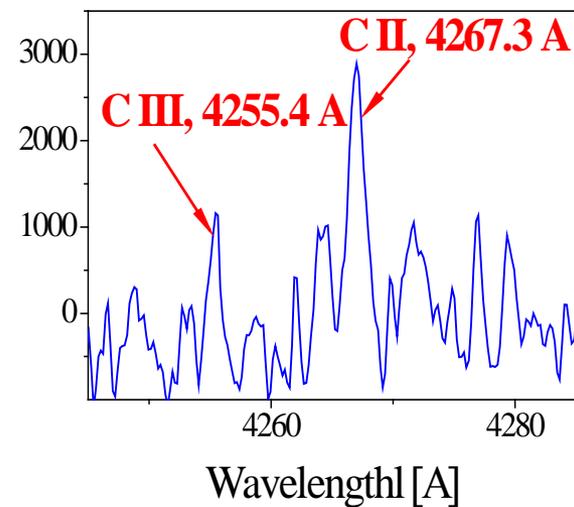
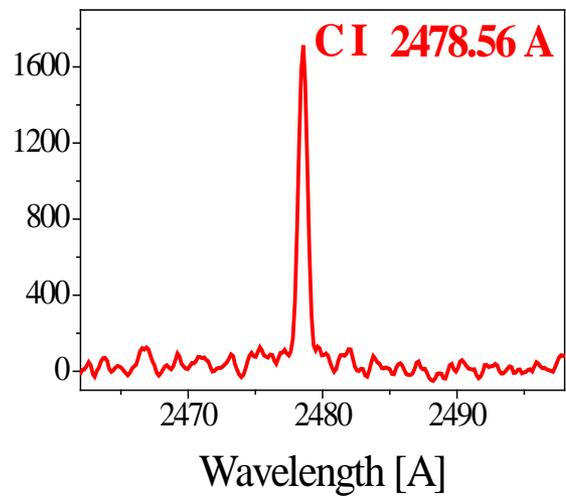
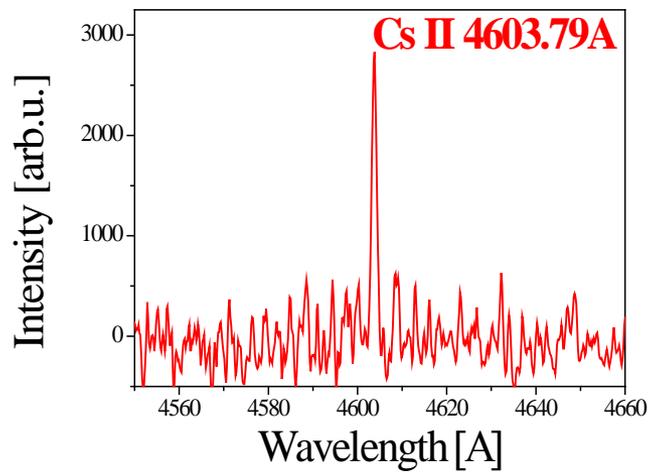
H α /H β population ratio

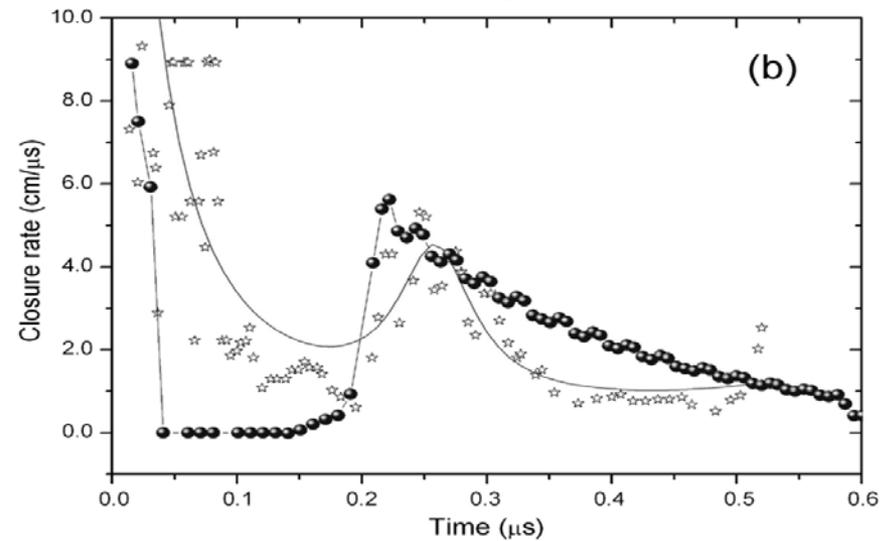
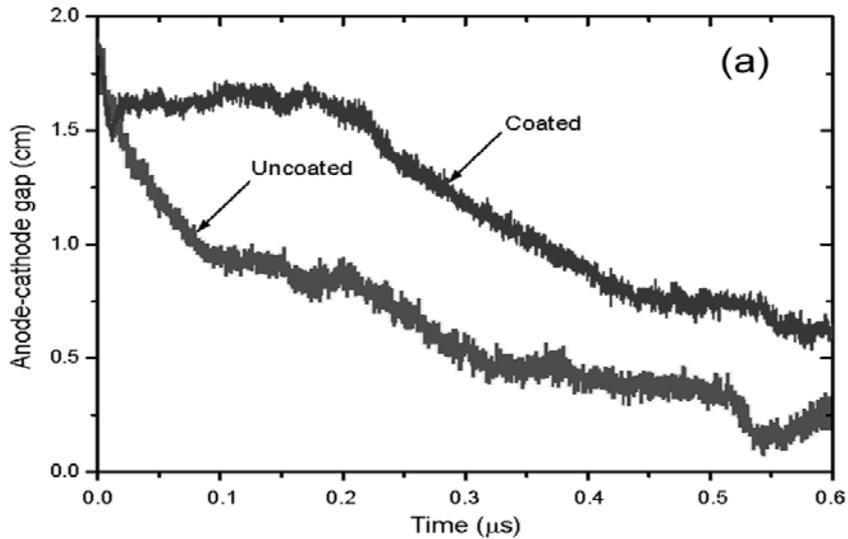


Collisional radiative modeling

Plasma electron temperature 7 ± 2
eV

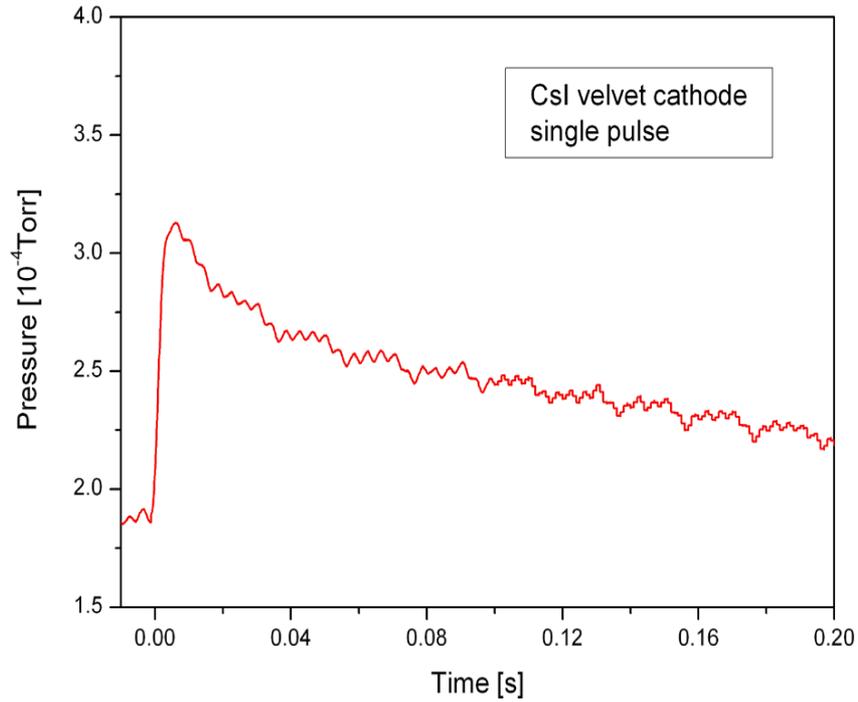
V.Vekselman, J.Gleizer, D.Yarmolich, J.Felsteiner, Ya.Krasik, **Lie Liu**, and V.Bernshtam, *Appl. Phys. Lett.*, vol. 93, 081503, 2008.



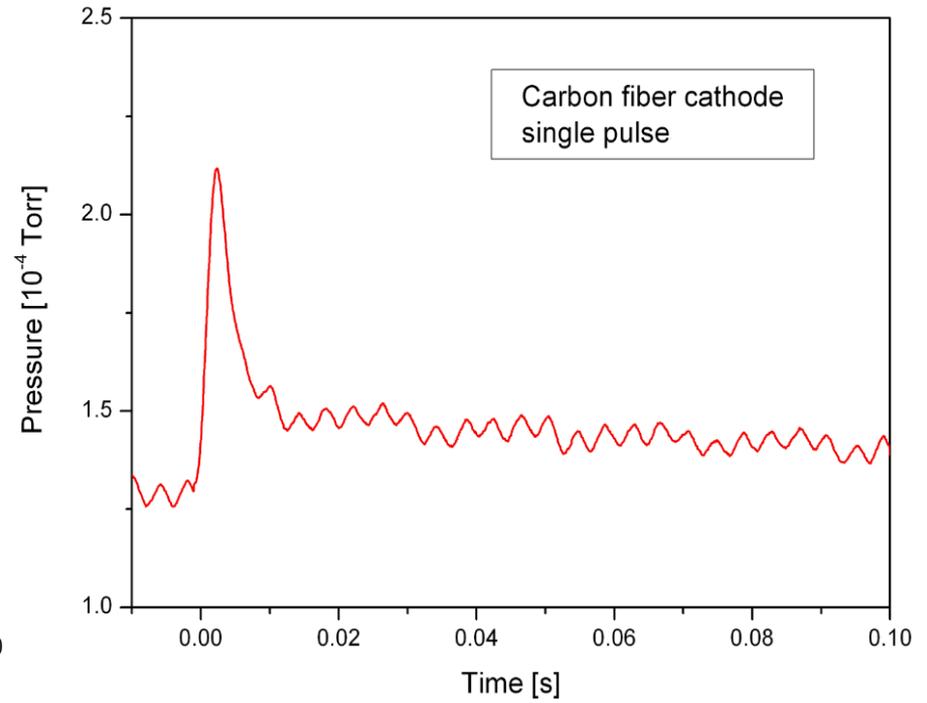


“Cs plasma” remains at the vicinity of the cathode surface, Cs II (4603.8 Å) was obtained only at the distance of 2.5mm from the cathode surface.

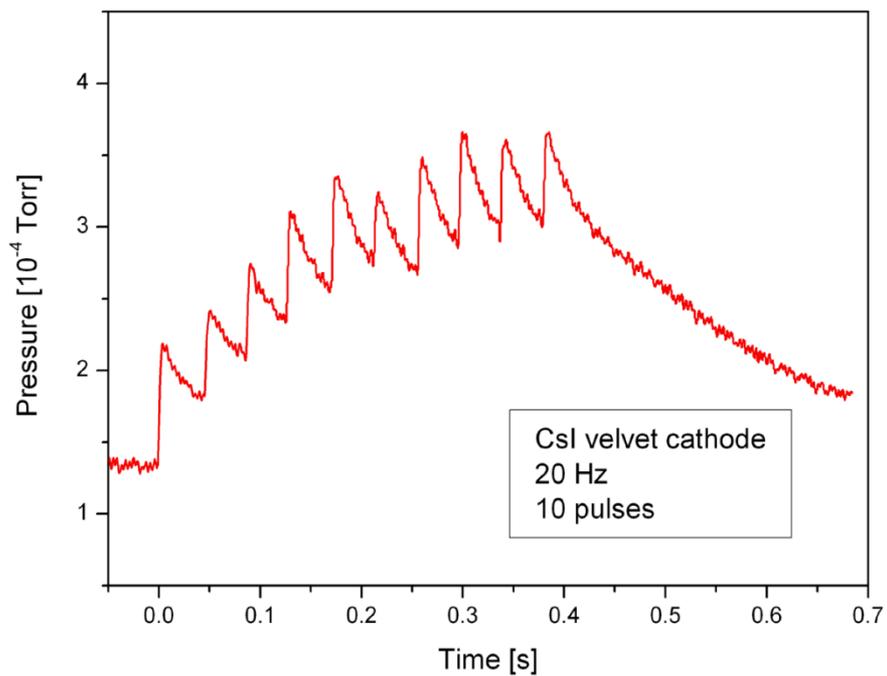
Vacuum compatibility



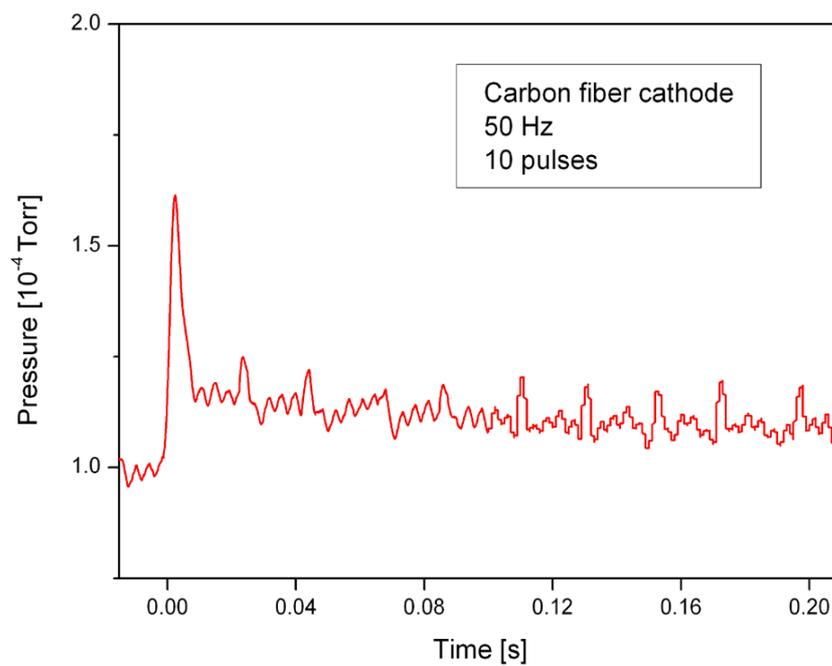
Velvet cathode



Carbon fiber cathode

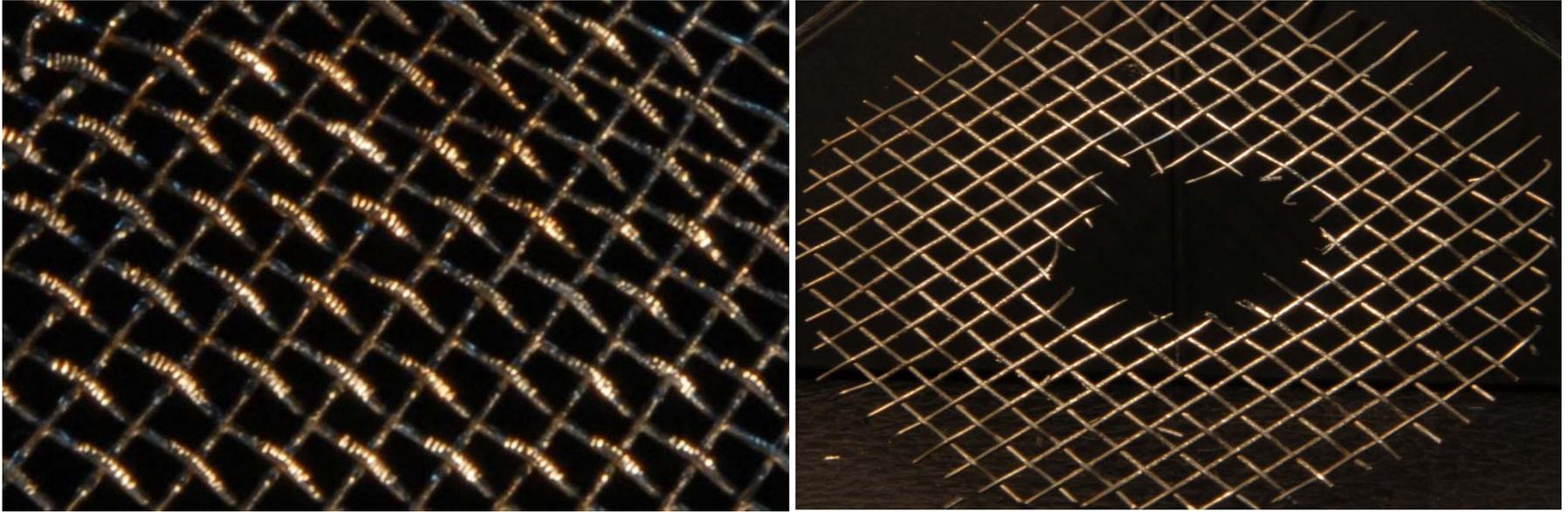


Velvet cathode, 20 Hz, 10 pulses



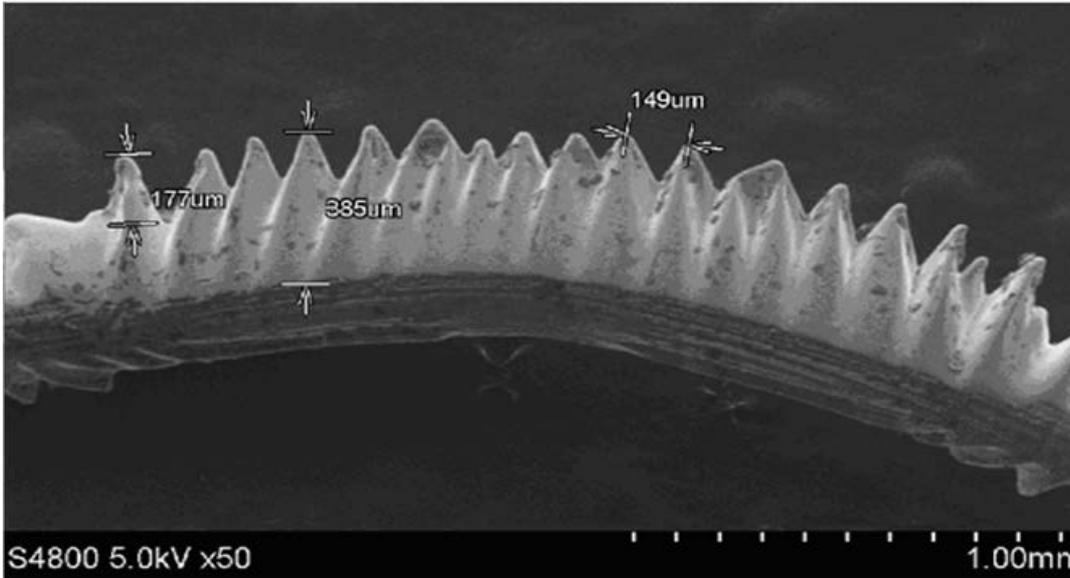
Carbon fiber cathode, 50 Hz, 10 pulses

3. Surface morphology of the stainless steel anode-grid irradiated by high-current electron beams



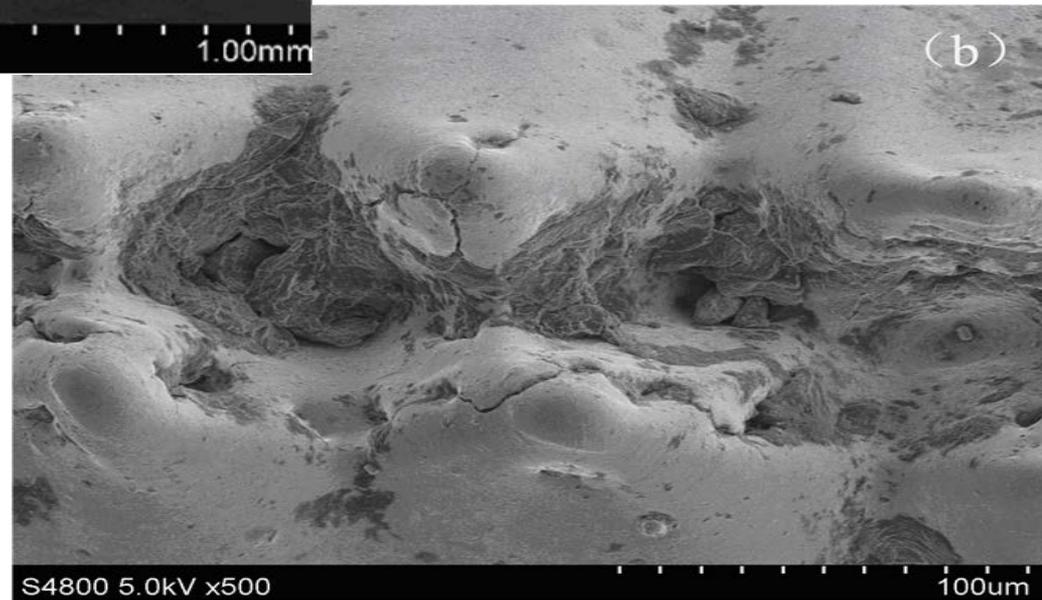
The anode grid is of 21 cm in diameter and 70% transparency.
The square grid cell's inner length is about 2.5 mm with cylindrical single wire of 0.3 mm in diameter.

Surface morphology of a single wire observed by a SEM in increasing magnification



Side view

Top view



Question:
Is it Rayleigh-Taylor-like
interface instability?

4. A series of tufted carbon fiber cathodes designed for different high power microwave sources



(a)

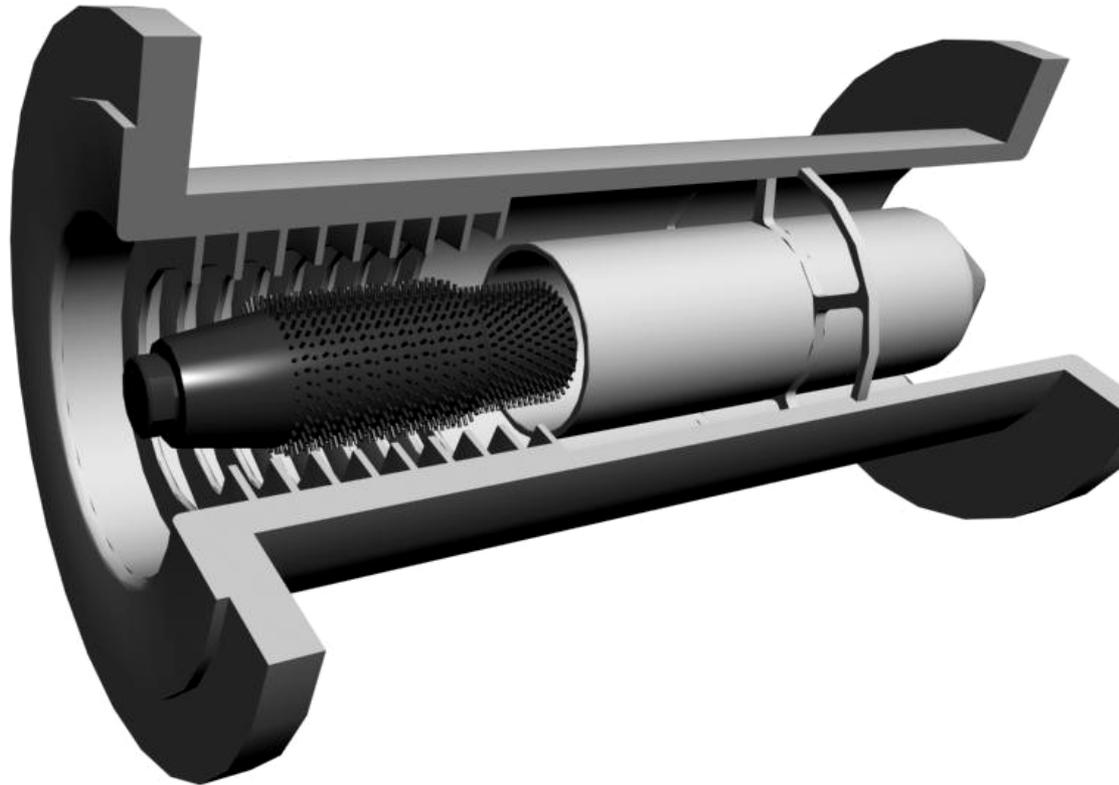


(b)

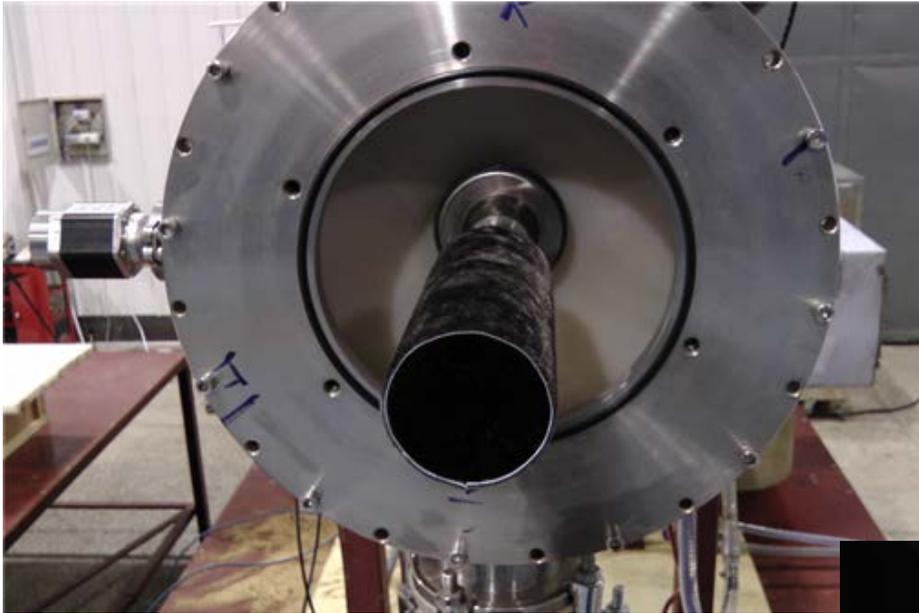


(c)

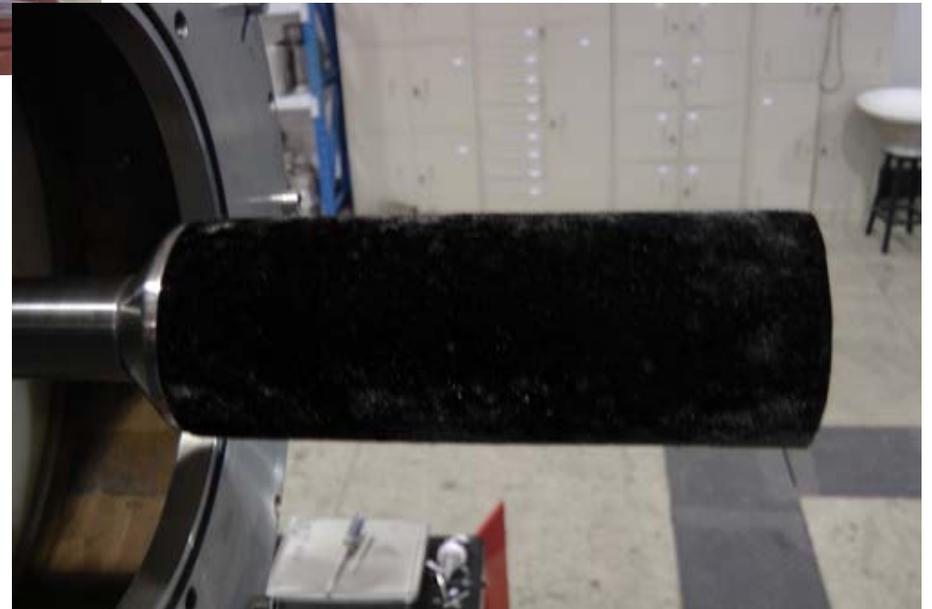
Carbon fiber-based cathodes for magnetically insulated transmission line oscillator (MILO) operation



Lie Liu, et al., Applied Physics Letters, vol. 91, p. 161504 (2007)



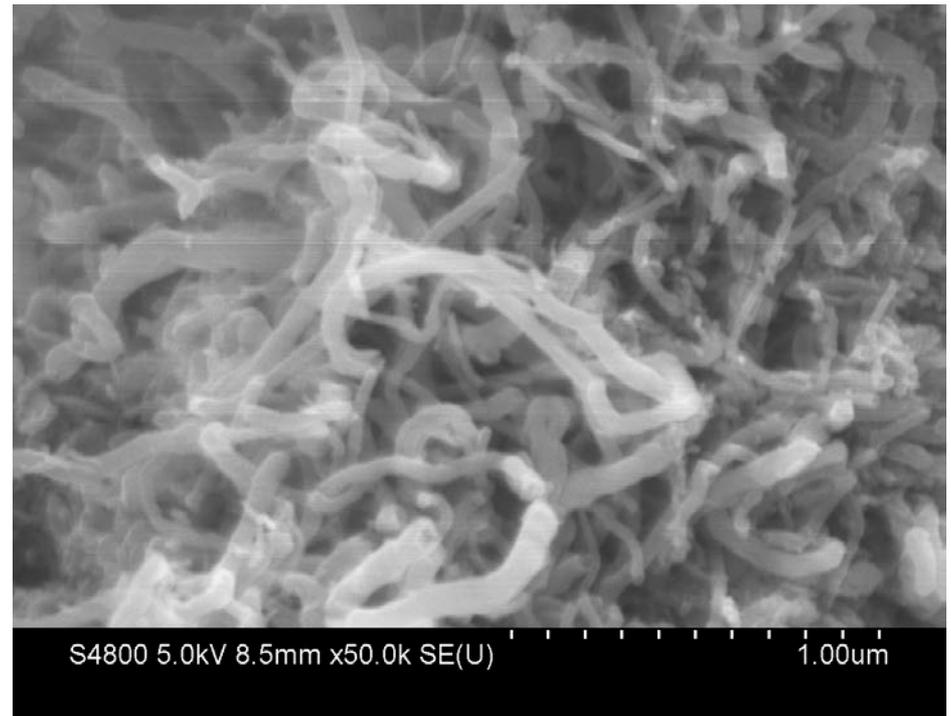
Large-Area
uniformly emitting



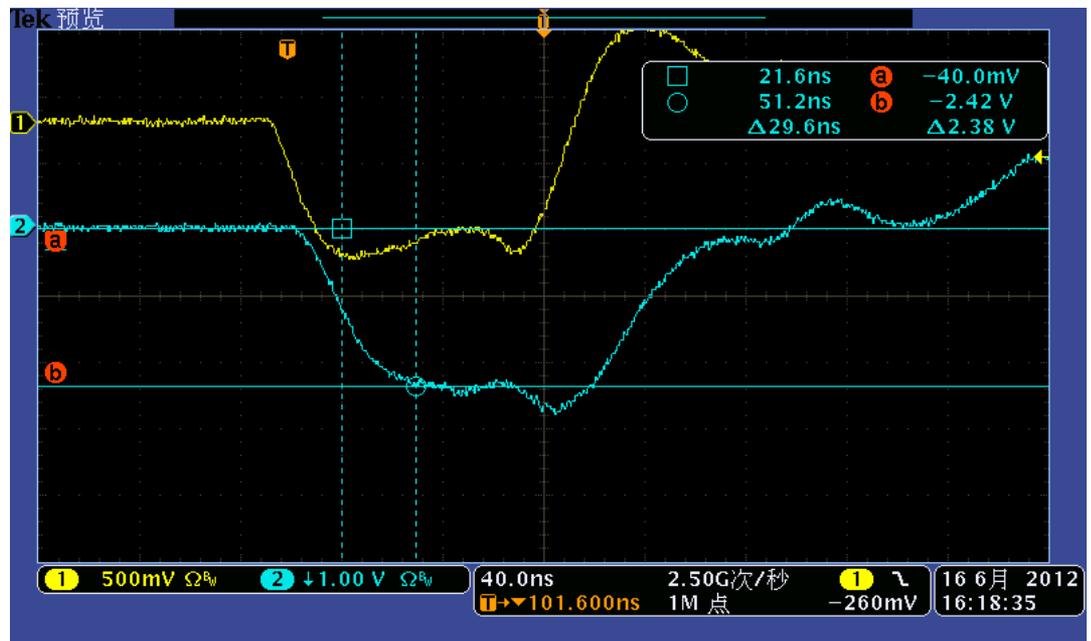
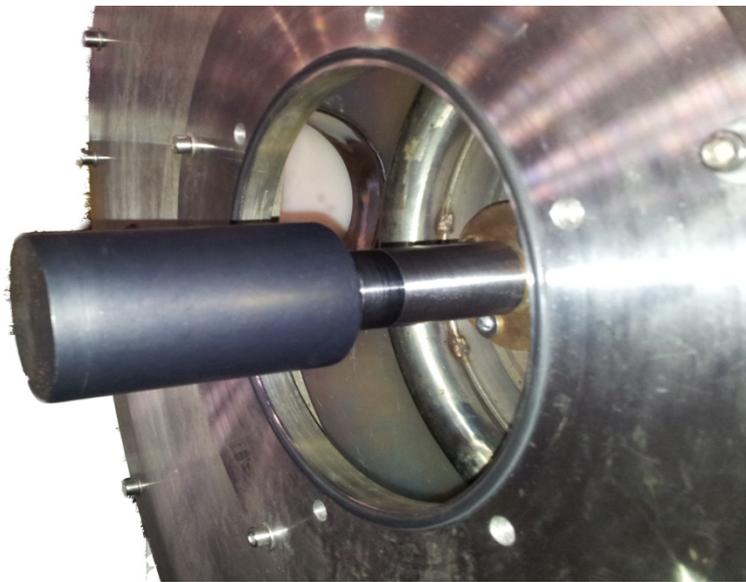
Carbon fiber velvet cathode for MIO operation

5. On-going research: cathode with carbon nanotube (CNT) coating

Large-area uniformly CNT on cathode surface



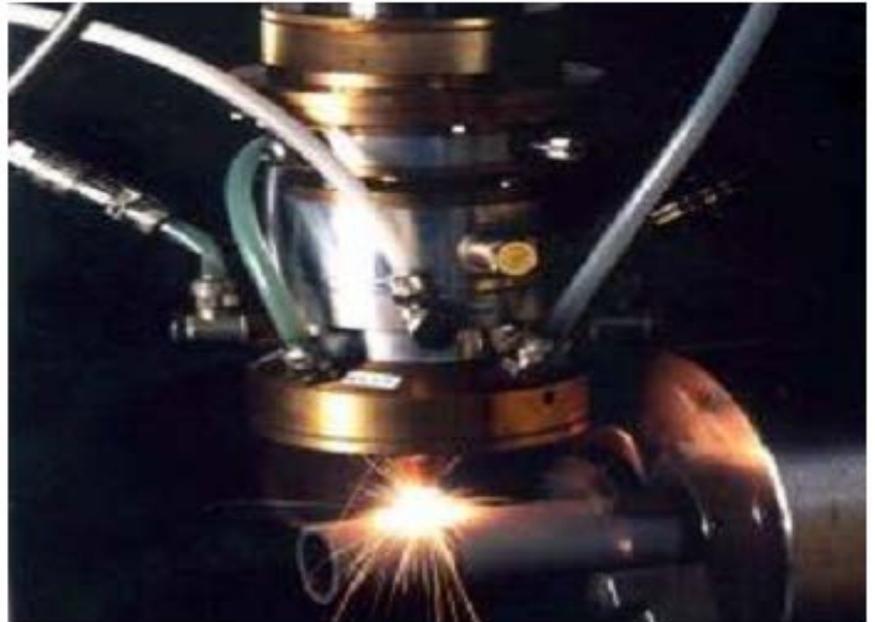
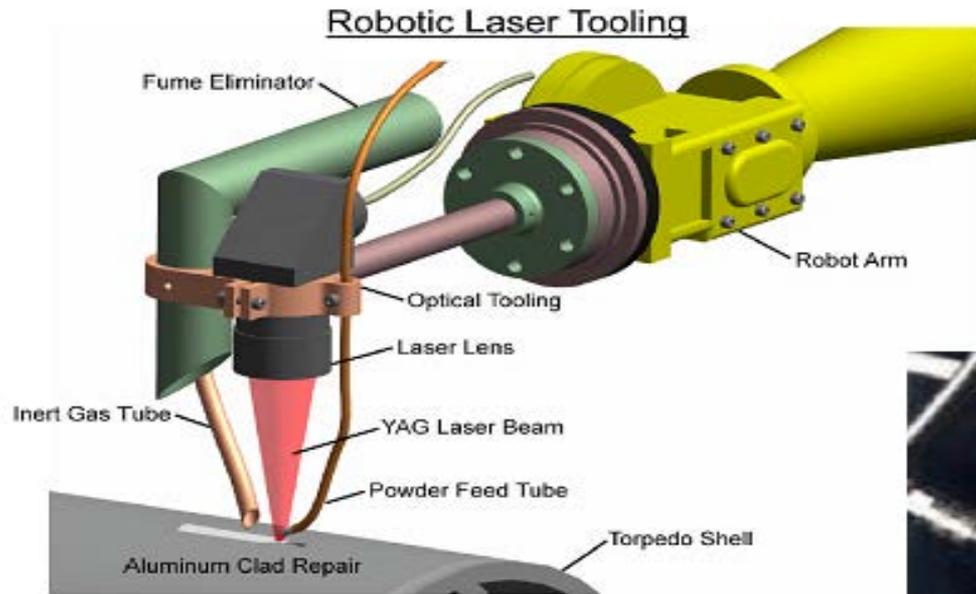
Scanning electron microscope (SEM) image of CNT on cathode surface



$U_d=318kV$

$I_d=84.5kA$

Laser cladding (or by high-current electron beams)

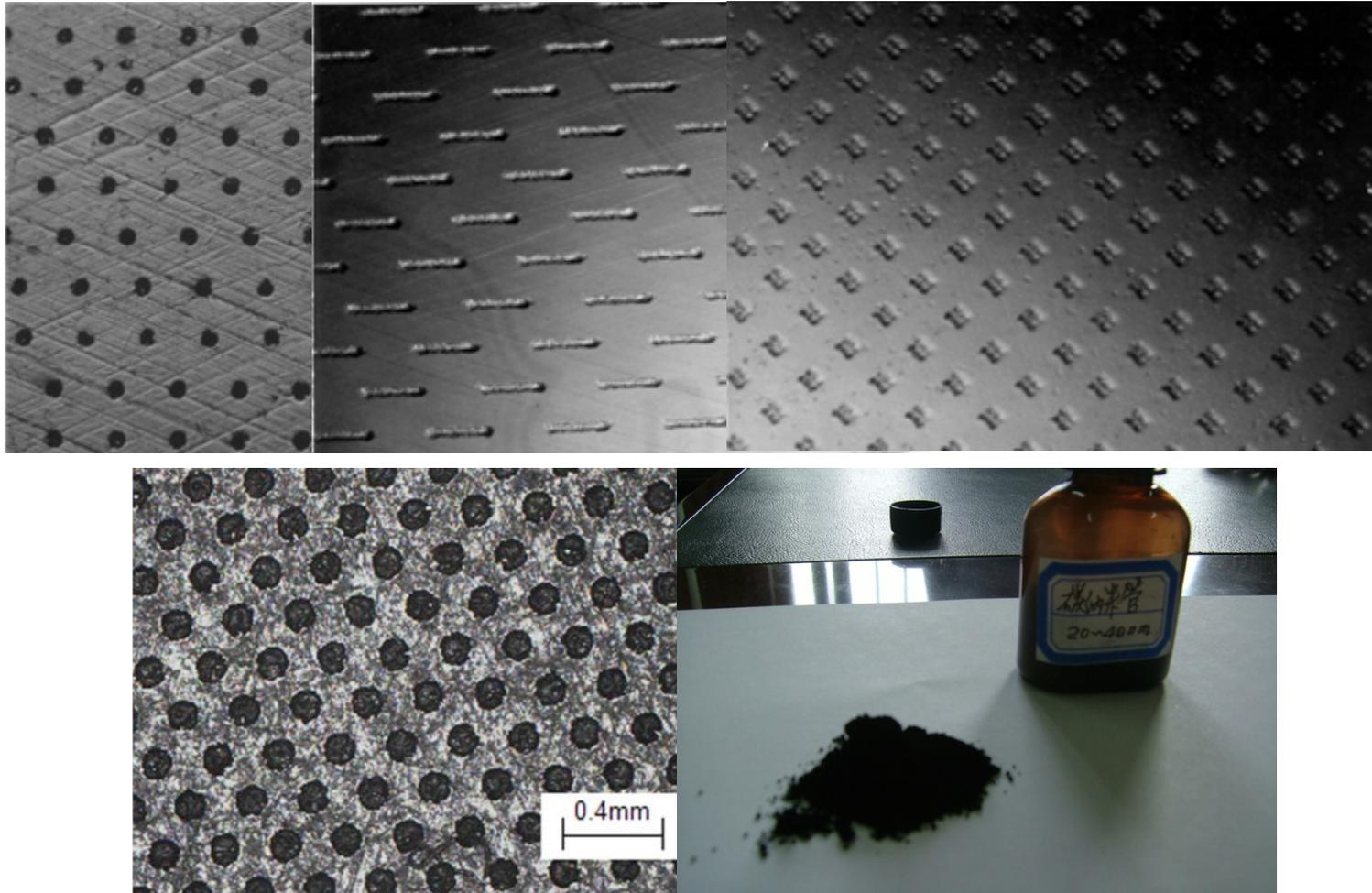


Laser cladding to make carbon nanotube cathode



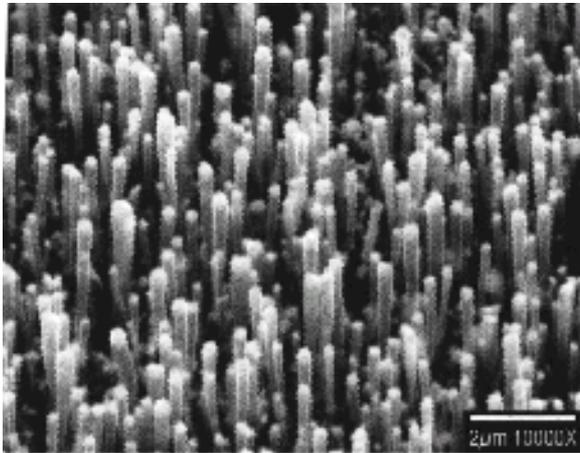
CNT cathode surface through laser cladding can generate field enhanced EEE and surface-flashover EEE.

What methods can be used to improve the cladding uniformity of carbon nanotube on a cathode?



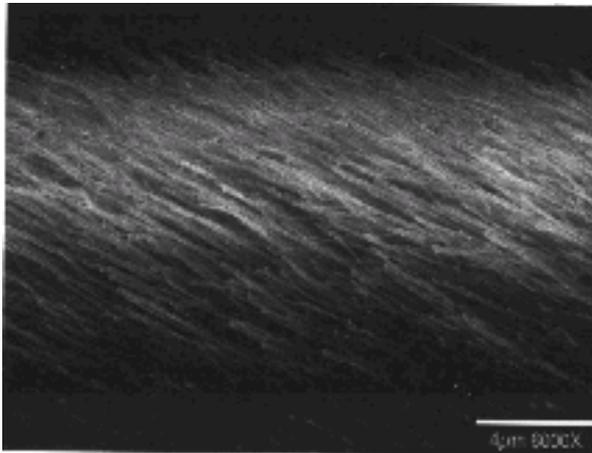
- oDigging holes on the surface of cathode uniformly
- oFill carbon nanotube powder into these holes
- oApply laser cladding to combine them together

Recent research breakthroughs include novel methods to precisely fabricate new high current density cathodes and improved understanding of cathode emission physics.



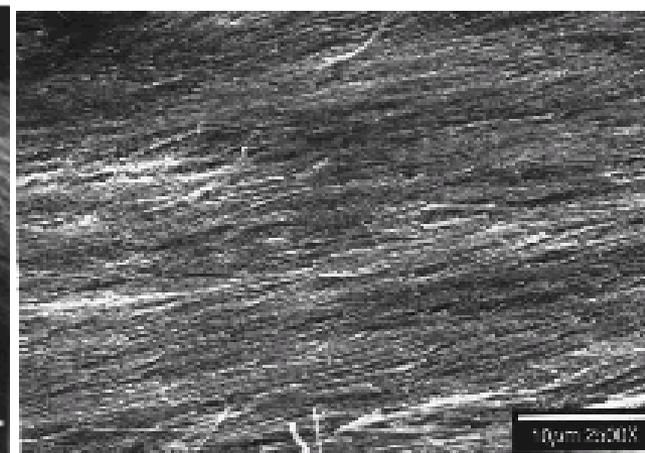
a;

90°



b;

45°



c;

0°

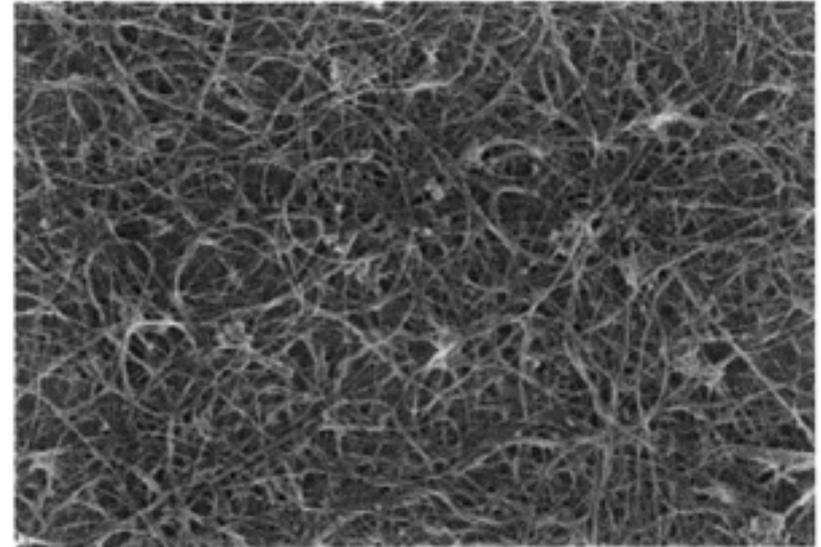
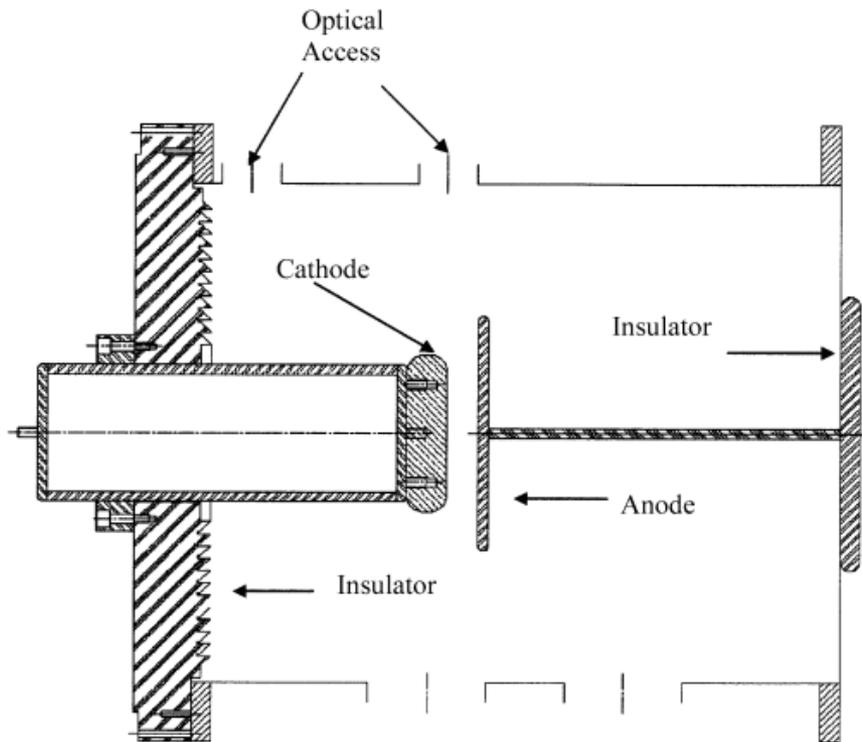


Fig. 1. Experimental configuration for cathode tests.

Results from US Air Force Research Lab

D. Shiffler et al., *IEEE transaction on Plasma Science*, Vol. 32, pp. 2152-2154 (2004)

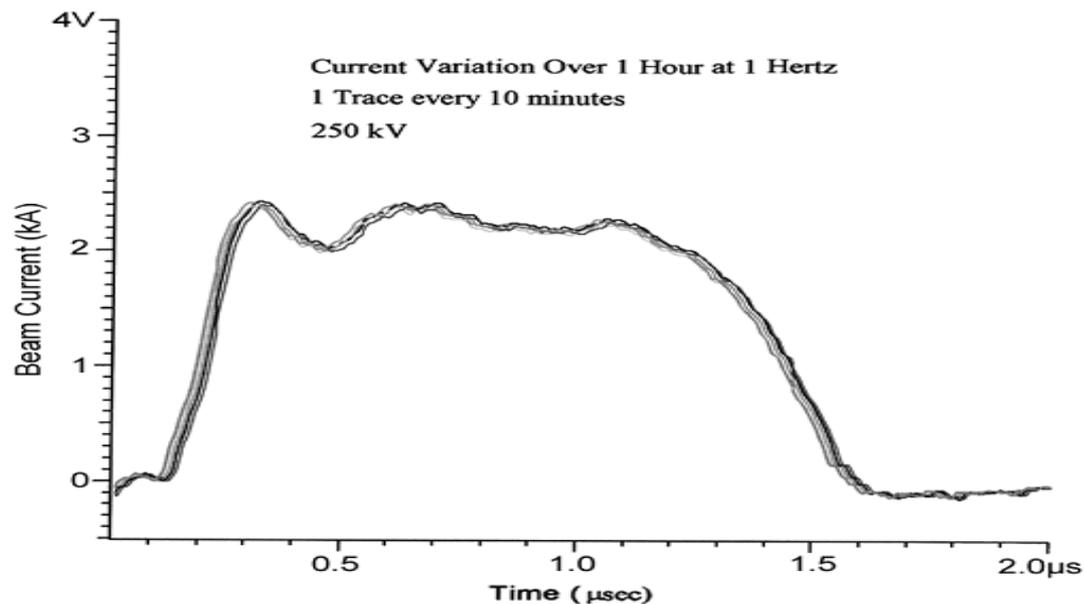


Fig. 4. Current obtained for operation at 250 kV over a period of 1 h. We acquired current data every 10 min. Current remains very stable throughout operation.

TABLE I
VOLTAGE, CURRENT, CURRENT DENSITY, AND SHOT NUMBERS FOR CNT CATHODE. NOTE THAT AVERAGE CURRENT DENSITY OVER MACROSCOPIC REACHES 50 A/cm^2

<u>Voltage (kV)</u>	<u>Current (kA)</u>	<u>Current Density (A/cm²)</u>	<u>Number of Shots</u>
137.5	0.8	12.5	5,000
165	1.3	20.3125	5,000
192.5	1.5	23.4375	5,000
220	1.7	26.5625	5,000
247.5	2.2	34.375	5,000
275	2.5	39.0625	5,000
302.5	3	46.875	5,000
330	3.3	51.5625	3,321

Results from China Academy of Engineering Physics & University of Science Technology Beijing

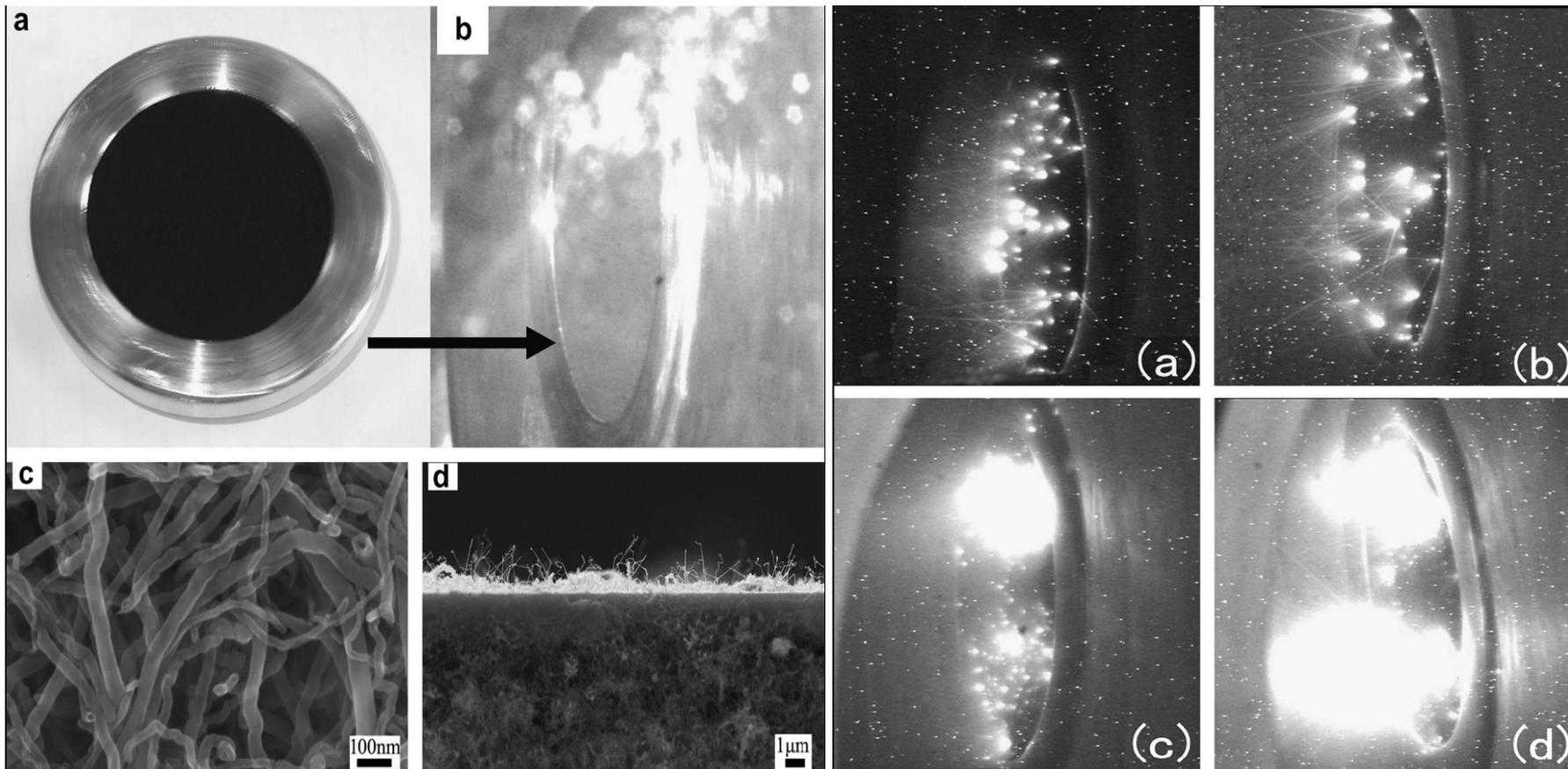


Image of CNT on cathode surface

Explosive field emission(1 MV) and plasma expansion

What one can get from the Project

1. Paper __ physics and more discussion

(Comments from APL referees about my papers)

Paper Interesting: Yes	Original Paper: Yes	Sufficient Physics: Yes
Well Organized: Yes	Clear and Error Free: Yes	Conclusions Supported: Yes
Appropriate Title: Yes	Good Abstract: Yes	Satisfactory English: No
Adequate References: Yes	Clear Figures: Yes	

2. Applications __ fabrications and materials

The cathode material:

Low electric field (<50 kV/cm) for electron emission, Nanosecond timescale turn-on,
Long life-time (>10⁷ pulses), High current densities (kA/cm²)

a slow plasma expansion rate (coating technique), Uniformity and arbitrary cross-section

Vacuum (10⁻⁴ – 10⁻⁵ Torr) compatibility (low outgassing rate), Low power consumption

The fabrication process and cathode structure: How to construct cathodes,

Robust (long life), easily shaped, free-epoxy and surface treatment technique of cathodes

Overall rating  Something new and detailed

Acknowledgement

National Natural Science Foundation of China
(No. 10975186).

Some optical assistant diagnostics of plasma in diode were accomplished during the author's visit in Physics Department of Technion-Israel, collaborating with Prof. Krasik and his group!

